

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	1	("hard mask" and (nitride or SiN or "silicon nitride") and (ARC or antireflect) and (resist or photoresist) and "etch stop" and plug and contact). clm.	US-PGPUB	OR	OFF	2006/03/23 09:48
L4	2	("hard mask" and (nitride or SiN or "silicon nitride") and (ARC or antireflect) and (resist or photoresist) and "etch stop" and plug and contact). clm.	US-PGPUB	OR	ON	2006/03/23 09:51
L5	30	lee-min-suk.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/23 09:52
L6	82	lee-sung-kwon.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/23 09:53